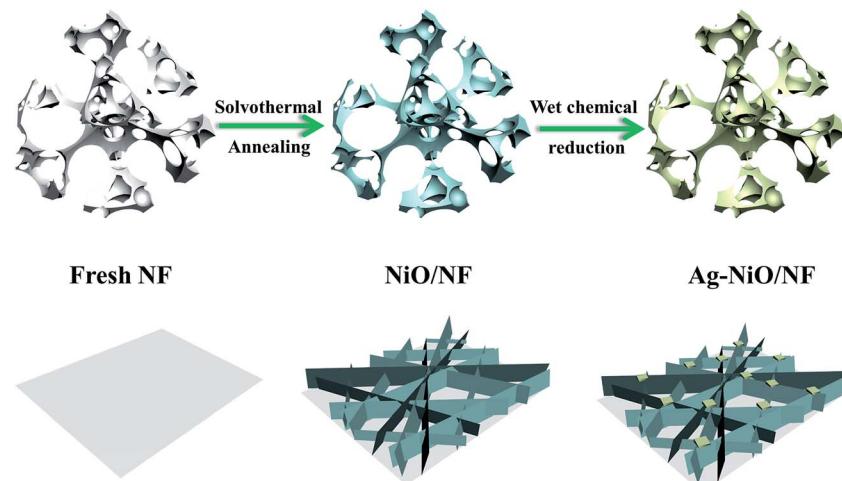




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Silver particle-loaded nickel oxide nanosheet arrays on nickel foam as advanced binder-free electrodes for aqueous asymmetric supercapacitors†

Shuxing Wu,^a Kwan San Hui,[†] Kwun Nam Hui,[†] Je Moon Yun,[†] and Kwang Ho Kim[†]                <img alt="ORCID iD icon" data-bbox="8644 25



Scheme 1 Schematic of the fabrication procedures of Ag-NiO/NF.

channels because of their outstanding electronic conductivity and durability.^{22,23} They also enhance the proton (H^+) diffusion throughout the electrode.²⁴ Vanitha *et al.* prepared Ag anchored CeO_2 /graphene nanocomposite; the nanocomposite electrode shows a high specific capacitance of 710.42 F g^{-1} at current density of 0.2 A g^{-1} , which is nearly twofold higher than CeO_2 /graphene nanocomposite.²⁵ Ma *et al.* synthesized Ag/ MnO_2 /graphene ternary nanocomposite; the ternary nanocomposite exhibits high specific capacitance of 467 F g^{-1} , which is much higher than that of MnO_2 /graphene nanocomposite (293 F g^{-1}).²⁶

In this study, we synthesized interconnected NiO nanosheets supported by nickel foam (NiO/NF) through a facile solvothermal method combined with a post-annealing process. Ag particles were loaded on the NiO/NF by use of a wet chemical reduction method of aqueous $AgNO_3$ solution. Scheme 1 shows a schematic of the fabrication process. Significant improvement was obtained after the loading of Ag particles. The Ag particle-loaded NiO/nickel foam (Ag-NiO/NF) electrode exhibited high specific capacitance (1254.9 F g^{-1} at 1 A g^{-1} and 914.3 F g^{-1} at 20 A g^{-1}) and good cycling stability (83.2% capacitance retention over 3000 cycles). Asymmetric SCs, which were comprised of Ag-NiO/NF as the positive electrode, reduced graphene oxide (rGO)⁷ as the negative electrode, and 6 M KOH aqueous solution as the electrolyte, were fabricated. The aqueous asymmetric SCs yielded a high specific capacitance of 97.9 F g at 1 A g^{-1} and a specific energy density of 26.7 W h kg^{-1} at a power density of 1017.1 W kg^{-1} and retained 77.8% of its initial capacitance after 3000 cycles.

2. Experimental section

2.1 Materials preparation

All chemicals used in this study were of analytical grade and were purchased from Sigma-Aldrich. NF were cleaned using acetone, concentrated HCl, ethanol and deionized (DI) water for 15 min. NiO nanosheets were synthesized directly on the NF ($2 \times 2\text{ cm}^2$) by immersing into the solution with $Ni(NO_3)_2 \cdot 6H_2O$ (0.7 g), urea (0.2 g), and ethanol (40 mL). The mixture was

transferred into 50 mL autoclave with a Teflon liner at $180\text{ }^\circ C$ and was then kept for 15 h. The obtained product was washed in an ultrasound bath with ethanol and DI water and dried at $60\text{ }^\circ C$ for 12 h. The samples were subsequently annealed in air at $300\text{ }^\circ C$ for 3 h to obtain nickel foam-supported NiO nanosheet arrays. The area density of NiO was nearly 1.91 mg cm^{-2} . Ag-NiO/NF was fabricated using the wet chemical reduction method. In a typical procedure, the as-prepared NiO/NF ($2 \times 2\text{ cm}^2$) was immersed in $AgNO_3$ aqueous solution (10 mL, 0.01 M) and then heated at $100\text{ }^\circ C$ for 5 h. Finally, the sample was washed with DI water and dried at $60\text{ }^\circ C$ for 12 h.

2.2 Materials characterization

The products were measured by X-ray diffraction (XRD) on a Rigaku MPA-2000 X-ray diffractometer with $Cu K\alpha$ radiation ($\lambda = 1.5418\text{ \AA}$) for the phase analysis. Scanning electron microscopy (SEM, Hitachi, S-4800) and transmission electron microscopy (TEM, FEI Talos, USA) were used to observe the morphology of the samples. X-ray photoelectron spectroscopy (XPS) was performed with the Thermo VG Escalab 250 photoelectron spectrometer.

2.3 Electrochemical tests

Ag-NiO/NF was directly used as the working electrode. Electrochemical measurements were carried out on an electrochemical working station (IviumNstat, Ivium Technologies) in a three-electrode system. The electrolyte was 6.0 M KOH aqueous solution, and the solution was degassed for 30 min using a sonicator. Saturated calomel electrode (SCE, Hg/Hg_2Cl_2) and Pt electrode were used as the reference and counter electrode, respectively. Cyclic voltammetry (CV), galvanostatic charge/discharge (GCD), and electrochemical impedance spectroscopy (EIS) were applied to confirm the capacitive behavior of Ag-NiO/NF electrodes. The EIS was conducted at an amplitude of 5 mV in the frequency range of 100 kHz to 10 mHz. The obtained GCD curves were used to calculate the specific capacitance (C_s) in accordance with the following equation:²⁷



$$C_s = \frac{2i_m}{V^2} \int \frac{V dt}{V_f - V_i}, \quad (1)$$

where $i_m = I/m$ (A g⁻¹) is the current density and V (V) is the potential window with initial (V_i) and final (V_f) values.

The performance of asymmetric SCs was also measured using CV and GCD. The anode electrode was fabricated mixing 85 wt% of rGO, 10% wt% of acetylene black, and 5% poly(tetrafluoroethylene). The energy (E) and power (P) densities were calculated using the following equations:

$$E = \frac{I \int V dt}{M}, \quad (2)$$

$$P = \frac{E}{\Delta t}, \quad (3)$$

where M is the total mass of both positive and negative electrodes.

3. Results and discussion

Ag particles were synthesized by wet chemical reduction without the presence of reducing agents. Recently, Nishimura *et al.* demonstrated that NaOH accelerates the reduction of Ag⁺ ions and nucleation of metallic Ag nanoparticles through the formation of Ag₂O intermediate.²⁸ In the current study, the -OH on the surface of NiO nanosheets caused the generation of Ag₂O (eqn (4)).²⁹ The self-redox reaction of Ag₂O could occur under the influence of indoor light. The photo-generated electrons and holes in Ag₂O could facilitate its redox reaction toward the generation of metallic Ag particles, as indicated in eqn (5) and (6).

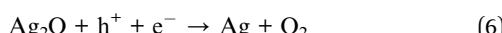
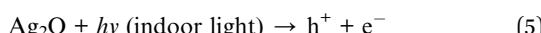
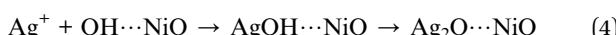


Fig. 1 shows the XRD patterns of NiO/NF and Ag-NiO/NF. NiO was superimposed on the pattern of NF substrate

(Fig. 1a). The XRD peaks of the NiO nanosheets corresponded to the cubic NiO phase (JCPDS no. 65-2901) and confirmed the formation of a highly crystalline structure after annealing at 300 °C. It was demonstrated that surface redox reactivity of an electrode material depends on its crystallinity, which can be optimized using the annealing temperature.³⁰ Previous works have shown that NiO annealed at 300 °C presents the highest electrochemical performance.^{31,32} Fig. 1b shows the XRD pattern of the Ag-NiO scraped from the substrate. The peaks located at around 38.1, 44.3, 64.5, and 77.4 could be indexed as the (111), (200), (220), and (311) planes of metal Ag (JCPDS no. 65-2871), respectively. The remaining diffraction peaks were consistent with the planes of NiO.

Fig. 2 shows the microstructures of NiO/NF and Ag-NiO/NF at different magnifications. NF was used as the current collector and provided efficient pathway for electron transport and reduced the diffusion resistance of the electrode due to its high electrical conductivity and 3D cross-linked structure.³³ After the solvothermal treatment and a subsequent annealing process, NiO nanosheets were grown uniformly on the nickel foam with a high density. These nanosheets possessed an average thickness of approximately 40 nm. These nanosheets connected with one another and aligned vertically, thereby resulting in the formation of porous structures. The porous NiO nanosheet arrays could offer effective penetration of electrolyte and abundant electroactive sites for redox reactions. In addition, the interconnected arrays could maintain the structural stability by relaxing volume expansion during the charge/discharge process. Compared with the SEM images of NiO/NF and Ag-NiO/NF in Fig. 2b, the interconnected arrays of NiO nanosheet were fully retained and Ag particles were uniformly deposited on the surface of NiO nanosheet arrays. The Ag particles could act as bridge for electron transfer, thus, electrochemical performance of NiO nanosheets could be enhanced.

From the TEM image of Ag-NiO/NF sample, Ag particles were found loaded onto the surface of NiO nanosheet (Fig. 3a). Fig. 3b elucidates the thin nature of NiO nanosheets by the folding silk-like morphology with curling folded edges and transparent feature. The selected-area electron diffraction (SAED, selected area: ~200 nm in diameter) exhibited

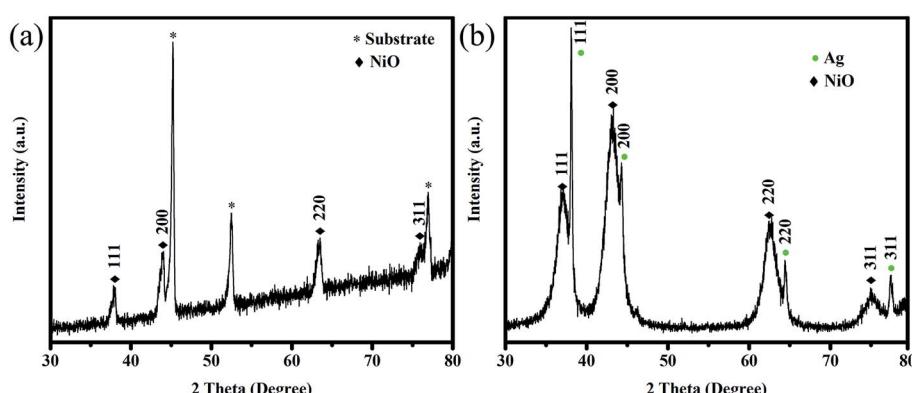


Fig. 1 XRD patterns of NiO/NF (a) and Ag-NiO powder scraped from samples (b).

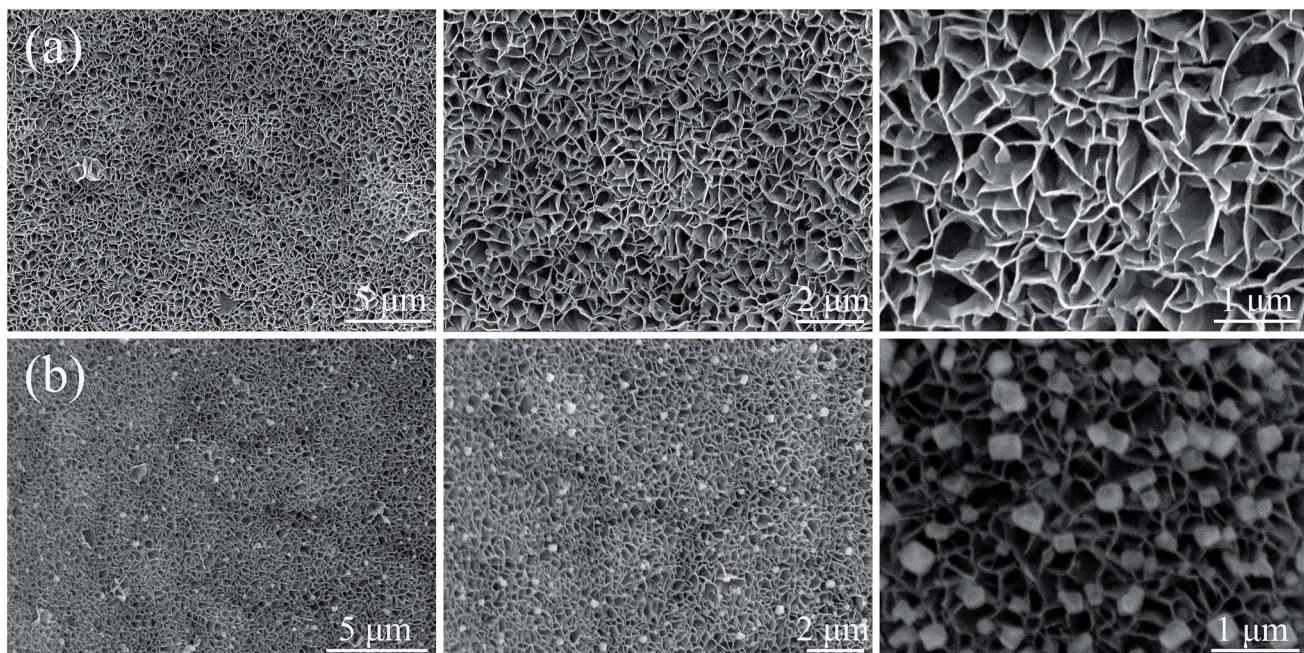


Fig. 2 SEM images of NiO/NF (a) and Ag-NiO/NF (b) at different magnifications.

polycrystalline rings, and the diffraction rings could be indexed as the (111), (200), (220), and (311) planes of the NiO phase (Fig. 3c). Fig. 3d shows a typical high-resolution TEM (HRTEM)

image of NiO nanosheets. The lattice spacing of 0.21 nm corresponded to the (200) plane of NiO. Fig. 3e shows the Ag particles of the surface of the NiO nanosheet. The lattice

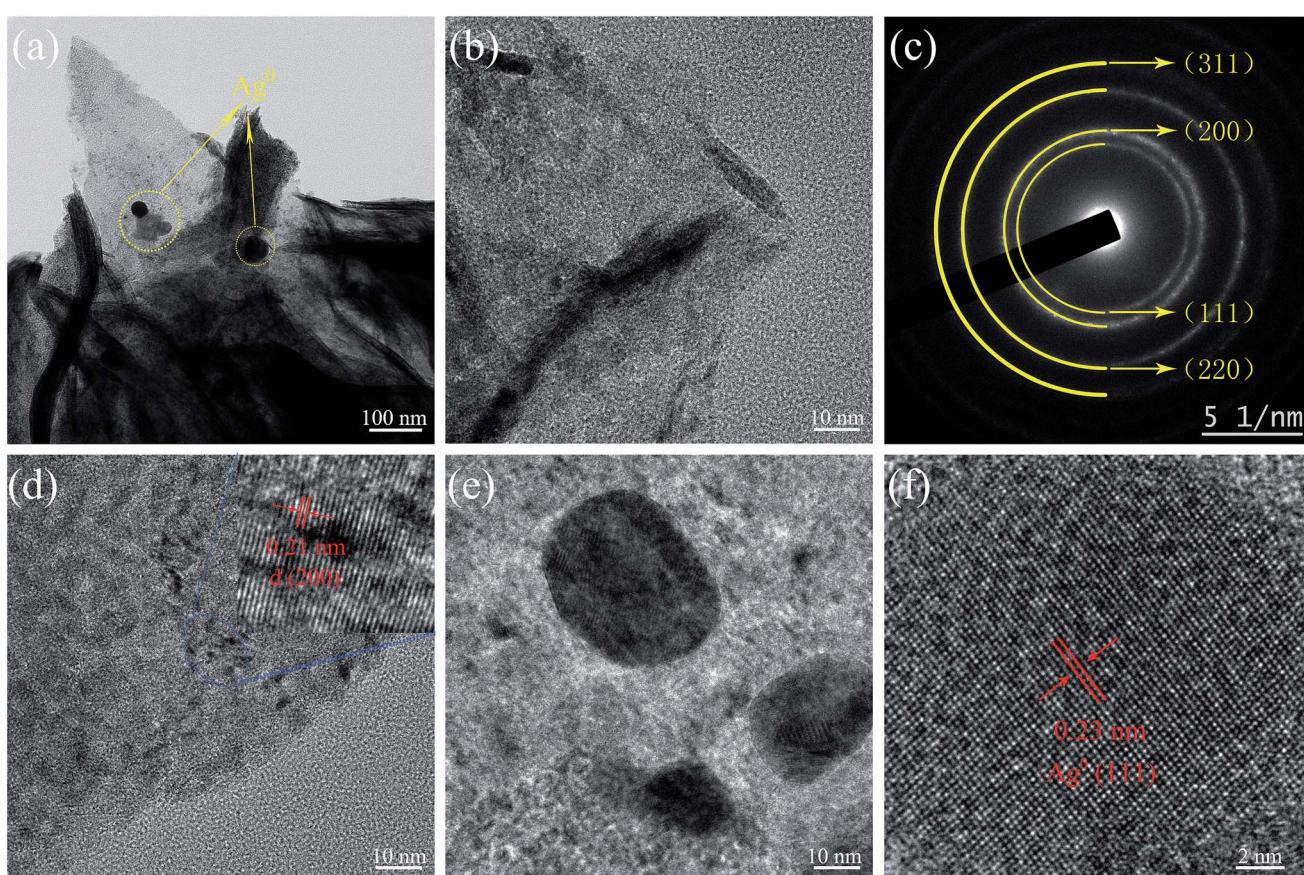


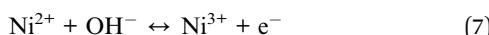
Fig. 3 TEM image of Ag-NiO/NF (a), HRTEM images (b and d) of NiO nanosheet, SAED pattern of NiO (c), and HRTEM images of metallic Ag (e and f).



spacing was 0.23 nm, which corresponded to the lattice spacing of the (111) planes for the Ag phase (Fig. 3f).

The surface states of Ag-NiO/NF were examined by XPS. The typical spectrum indicated the existence of Ni, Ag, C and O elements (Fig. 4a). The Ag 3d core level spectrum is shown in Fig. 4b. Two peaks observed at 374.2 and 368.1 eV could be attributed to Ag 3d_{3/2} and Ag 3d_{5/2}, respectively. These values and the 6.1 eV splitting of the 3d doublet signal suggest the existence of metallic Ag, which also agree with previous reports.^{34,35}

We further systematically studied the electrochemical performance of the electrodes in terms of CV, EIS, and GCD. Fig. 5a shows the CV curves of bulk NF, NiO/NF, and Ag-NiO/NF at a scan rate of 5 mV s⁻¹. The straight line (flattened due to scale difference) was observed for pure NF; therefore, the capacitance of NF is negligible. In the case of NiO/NF and Ag-NiO/NF, well-defined redox from 0 V to 0.5 V *versus* SCE was observed, which originated from the faradaic reactions of Ni²⁺/Ni³⁺ associated with OH⁻ (eqn (7)).³⁶



Notably, the CV curves of NiO/NF and Ag-NiO/NF showed symmetrical shapes; therefore, the faradaic reaction of Ni²⁺/Ni³⁺ is responsible for the improved capacitance performance. The CV curves of Ag-NiO/NF electrode had a larger integral area than those of the NiO/NF electrode; therefore, Ag-NiO/NF electrode exhibits superior electrochemical capacitance. Furthermore, the high electrochemical properties of the Ag-NiO/NF electrode are attributed to the loading of Ag particles providing rapid electronic pathways. Fig. 5b shows the typical CV curves of as-synthesized Ag-NiO/NF electrode at sweep rates of 5, 10, 30, 50, and 100 mV s⁻¹. A pair of redox peaks with symmetric characteristic could be identified in the CV curves, suggesting a high reversibility of the fast charge/discharge response. The peak current significantly increased with the increase in sweep rate. The shape of the CV curves was insignificantly influenced by the increasing sweep rate due to the enhanced electrolyte ions diffusion from open 2D structure of NiO nanosheets and the superior electronic conductivity of NF and Ag particles.

Fig. 5c shows the GCD curves of the Ag-NiO/NF electrode at different current densities in the range of 1–20 A g⁻¹ in a potential window of 0–0.4 V. A distinct plateau could be observed in the GCD curves, which corresponded to the forward reaction in eqn (7).³⁷ The GCD curves displayed great symmetry; therefore, excellent reversible redox reactions occur. The gravimetric capacitances of NiO/NF electrode (Fig. S1†) and Ag-NiO/NF electrode (Fig. 5d) were further calculated and plotted as a function of current density. The specific capacitances of Ag-NiO/NF electrode were 1254.9, 1183.2, 1137.6, 1054.6, and 914.3 F g⁻¹ at different current densities of 1, 3, 5, 10, and 20 A g⁻¹, respectively. Impressively, Ag-NiO/NF electrode preserved approximately 73% of specific capacitance delivered at 1 A g⁻¹ as the current density increased to 20 A g⁻¹, indicating high-rate capability. The increase in current density led to the decrease in specific capacitance, which was probably caused by the resistance of NiO nanosheets and the insufficient faradaic redox reaction of NiO nanosheets under high discharge current densities.

In EIS spectrum, the intercept of the curve at the real Z' axis at high frequencies represents the resistance of the electrochemical system (R_s) and the semicircular diameter reflect the charge-transfer resistance (R_{ct}); meanwhile, at a low frequency, the slope of the spike indicates the ion diffusion. The Nyquist plots of NiO/NF electrode and Ag-NiO/NF electrode are shown in Fig. 5e. The Nyquist plots exhibited one semicircle in the high frequency region and an inclined line in the low-frequency region. R_s for Ag-NiO/NF electrode was 0.39, which is lower than that of NiO/NF electrode (0.46); therefore, the Ag-NiO/NF electrode exhibits high conductivity. The small diameter of the semicircle suggested that Ag particles in the Ag-NiO/NF electrode presented a satisfactory electron pathway for efficient electron transport. In the low-frequency region, EIS of Ag-NiO/NF electrode presented a more vertical straight line along the imaginary axis, implying lower diffusion resistance of the structure.

The specific capacitances were plotted against the number of the GCD cycles for up to 3000 cycles to determine the stability of the electrodes (Fig. 5f). The retention of specific capacitance of Ag-NiO/NF electrode was 83.2% after 3000 cycles, which is

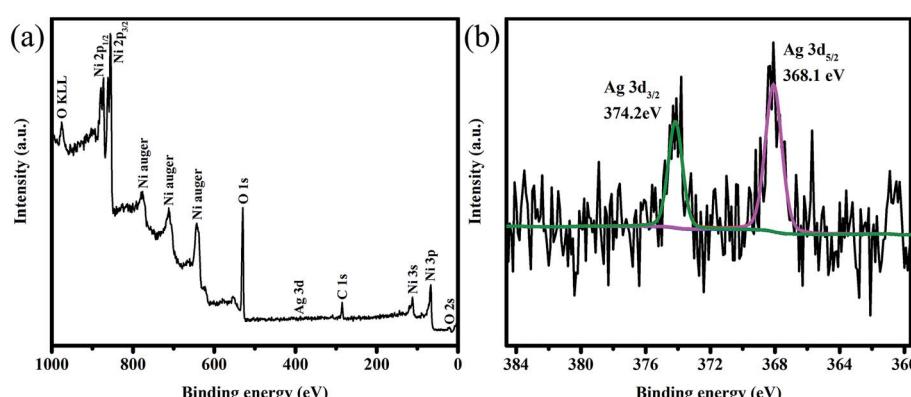


Fig. 4 XPS survey spectra of Ag-NiO/NF (a) and high-resolution XPS spectrum of Ag 3d (b).



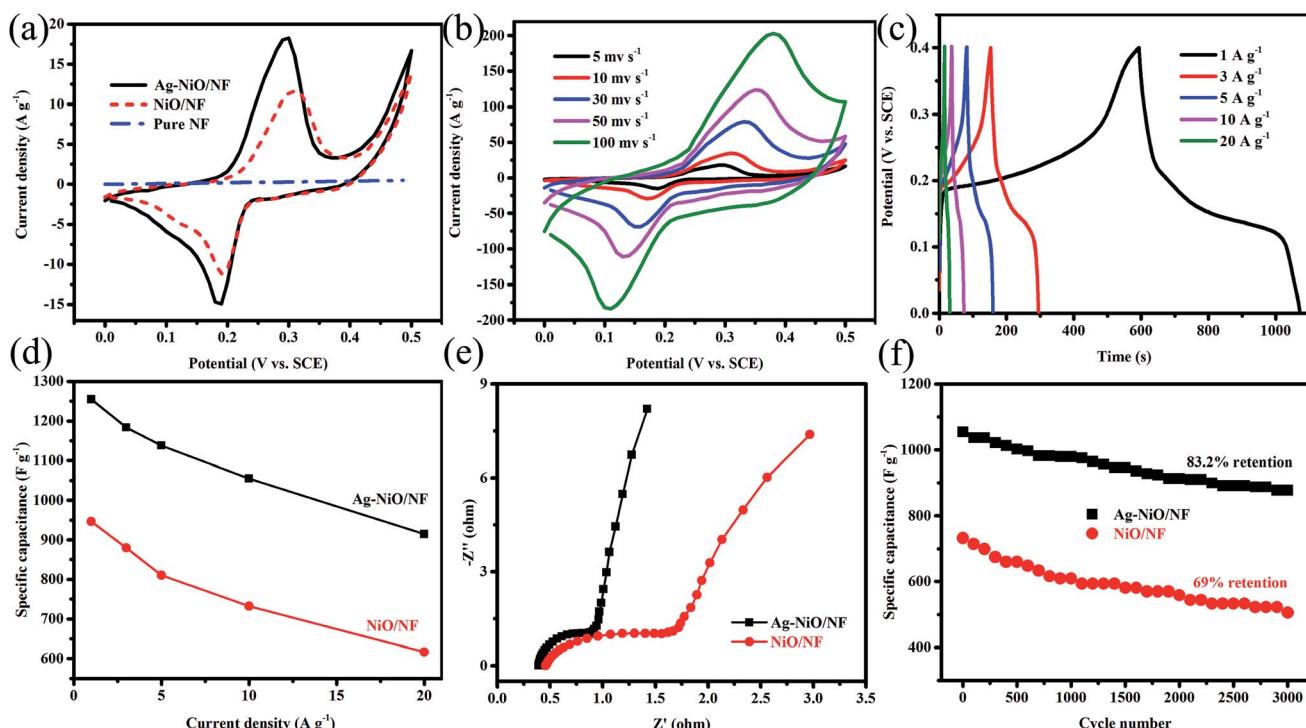


Fig. 5 CV curves of Ag-NiO/NF compared with NiO/NF and NF at a scan rate of 5 mV s^{-1} (a), CV curves of the Ag-NiO/NF at different scan rates (b), GCD curves of Ag-NiO/NF at various current densities (c), specific capacitance of Ag-NiO/NF and NiO/NF at different current densities (d), Nyquist plots of Ag-NiO/NF and NiO/NF (e), and cycling performance of Ag-NiO/NF and NiO/NF (f).

higher than that of NiO/NF (69%). The above-mentioned electrochemical testing results suggested that Ag-NiO/NF electrode possessed high specific capacitances and great cycling stability. This high electrochemical performance could be attributed to the unique features of the electrode as follows: (1) the direct growth of NiO nanosheets on NF generated binder-free electrode and the binder-free electrode not only reduced the “dead volume” but also favored the electron transfer; (2) the electrochemically active sites of the NiO nanosheets could be efficiently exposed to the electrolyte due to their 2D structure; (3) the interconnecting network provided continuous electron conducting pathways;³⁸ (4) the excellent adhesion between NiO nanosheet arrays and NF ensured the structural integrity; (5) the presence of Ag particles provided the least resistance path electron, thereby improving the specific capacitance.

ASC devices were fabricated using the as-prepared Ag-NiO/NF and rGO as the cathode and anode electrodes, respectively. A piece of polypropylene paper was used as the separator. Both electrodes were immersed into 6 M KOH along with separator and packed into CR2032 full cell (Fig. 6a). The specific capacitance of the rGO electrode was 178 F g^{-1} when the current density was 1 A g^{-1} . CV curves of Ag-NiO/NF electrodes and rGO electrodes at a scan rate of 5 mV s^{-1} revealed that the Ag-NiO/NF electrodes and rGO electrodes have stable potential windows of $0\text{--}0.5 \text{ V}$ and $-1\text{--}0 \text{ V}$, respectively (Fig. 6b). According to the equation $\frac{1}{C_{\text{total}}} = \frac{1}{C_{\text{cathode}}} + \frac{1}{C_{\text{anode}}}$, the charge storage capacity of cathode and anode electrodes should be balanced to obtain a high electrochemical performance. The charge balance

between the two electrodes should follow the equation $q^+ = q^-$. The stored charge is related to the specific capacitance (C), the potential windows obtained in the three-electrode measure (ΔV), and the mass of the electrodes (m), which follows the relationship $q = C \times \Delta V \times m$. The NiO to rGO mass ratio was calculated by the following equation: $\frac{m^+}{m^-} = \frac{C^- \times \Delta V^-}{C^+ \times \Delta V^+}$. The NiO to rGO mass ratio was adjusted to be 2.8 : 1.

Fig. 6c shows typical CV curves for the Ag-NiO/NF//rGO⁷ ASC in 6 M KOH (aq) electrolyte at various scan rates in the range from 0–1.4 V. Two redox peaks were observed, and they suggested the faradaic capacitance nature of the Ag-NiO/NF//rGO capacitor arising from the Ag-NiO/NF electrode. GCD curves at different current densities from 1 A g^{-1} to 20 A g^{-1} are shown in Fig. 6d. No obvious Ir drop was observed, suggesting a low internal resistance for the ASC. The GCD curves exhibited symmetric profiles, indicating an excellent electrochemical reversibility. The relationship between specific capacitance and current density is plotted in Fig. S2.† The calculated specific capacitances of the ASC (based on the total mass of the active materials of the two electrodes) were 97.9 , 86.0 , 73.4 , 67.3 , and 52.9 F g^{-1} at 1 , 3 , 5 , 10 , and 20 A g^{-1} , respectively; therefore, the ASC presents high-rate capability.

Energy and power densities are two important parameters that can be used to evaluate the electrochemical performance of a full cell. The Ragone plot of Ag-NiO/NF//rGO ASC device based on GCD measurements is shown in Fig. 6e. A maximum energy density of 26.7 W h kg^{-1} was obtained at power density of 1017.1 W kg^{-1} . The energy density was maintained at 14.4 W h kg^{-1} when



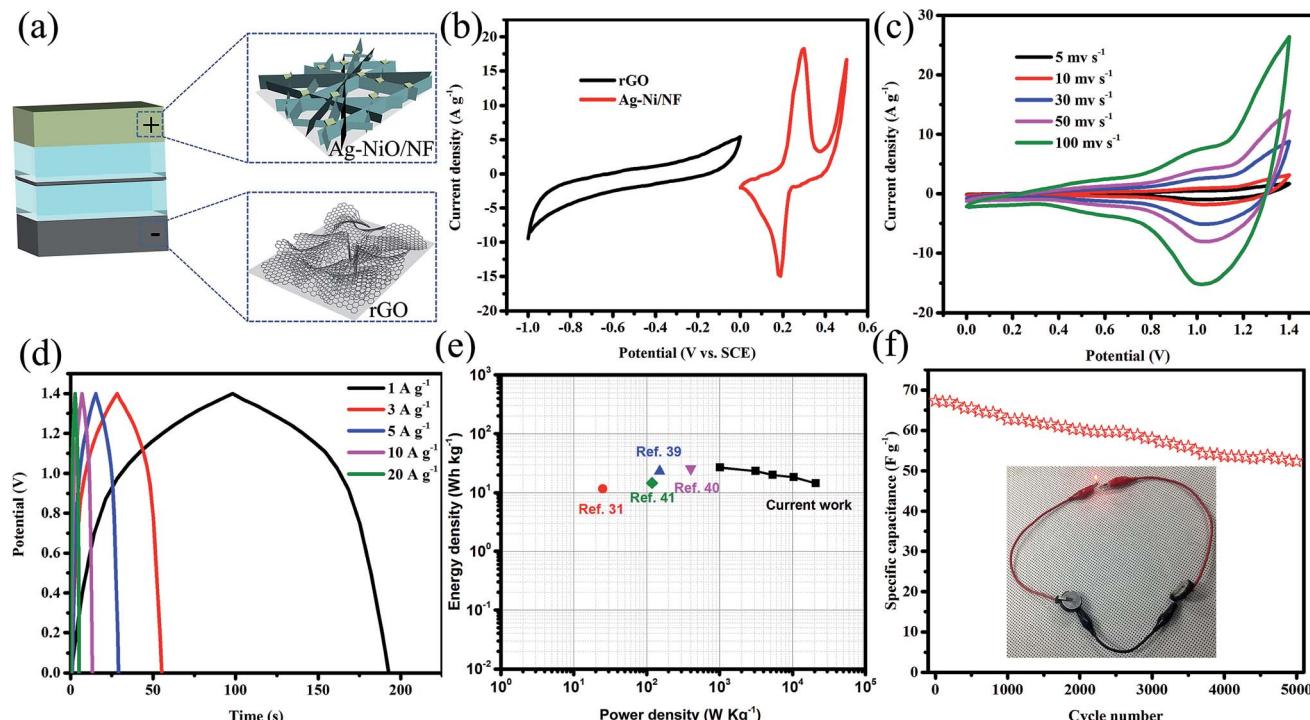


Fig. 6 Schematic of the as-assembled Ag-NiO/NF//rGO ASC device (a), comparative CV curves of Ag-NiO/NF and rGO in a three-electrode system at a scan rate of 5 mV s^{-1} (b), CV (c) and GCD (d) curves of Ag-NiO/NF//rGO ASC device at different scan rates, Ragone plot of the Ag-NiO/NF//rGO ASC device in comparison with that of many previously reported asymmetric SCs (e), and cycling stability over 5000 cycles, inset shows an LED lit by two series connected ASC devices (f).

the power density increased to $20\ 869.6 \text{ W kg}^{-1}$. The energy and power densities of our ASC device were superior to those of many other previously reported NiO-based ASCs, such as NiO/C (11.6 W h kg^{-1}),³¹ NiO//rGO ($23.25 \text{ W h kg}^{-1}$),³⁹ CNT@NiO//PCPs (25.4 W h kg^{-1}),⁴⁰ NiO/C (14.6 W h kg^{-1}).⁴¹ Cycling performance was measured by charging and discharging the devices 3000 times at a current density 10 A g^{-1} (Fig. 6f). A total of 77.8% of initial capacitance of the device remained after 3000 charge/discharge cycles. The applicability could be proved visibly by powering red light-emitting diodes (LEDs). The serially connected two ASC devices lighted up the commercial LED, as displayed in the inset of Fig. 6f.

4. Conclusions

In this study, surface loading of NiO/NF with Ag particles was prepared using a wet chemical method. NiO nanosheet arrays were grown vertically on the NF, which served as a conducting scaffold to improve the conductive nature. The anchored Ag particles further increased the electronic conductivity. The electrochemical properties of the Ag-NiO/NF electrode resulted in superior specific capacitance of 1254.9 F g^{-1} at 1 A g^{-1} over that of the NiO/NF (946.3 F g^{-1}) at a current density of 1 A g^{-1} . Furthermore, ASC devices were assembled with Ag-NiO/NF and rGO in 6 M KOH. The ASC device delivered a high energy density of 26.7 W h kg^{-1} and the power density of $20\ 869.6 \text{ W kg}^{-1}$ with the potential window of 1.4 V . Moreover, the assembled devices

exhibited a good cycling stability with 77.8% initial capacitance retention after 3000 cycles.

Conflicts of interest

There are no conflicts to declare.

Acknowledgements

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